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Enhanced photoresponse in a $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ heterojunction based visible light photodetector†

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Ag_2S and In_2Se_3 , two prominent functional materials, have recently gained extensive research attention. Ag_2S shows good chemical stability with excellent photoconducting ability as a direct, narrow band-gap semiconductor. In_2Se_3 compounds have been widely used in optoelectronics, photodetectors, and gas sensors. In this work, we develop a visible light photodetector by combining these two materials from $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ heterostructure films at room temperature. The $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ bilayer films were annealed at different temperatures, and their photodetection parameters were compared to different annealed films. The bilayer structure and the interdiffusion of Ag_2S into the In_2Se_3 layer were confirmed through a cross-sectional FESEM view. The 250 °C annealed sample shows better photoconductivity with a maximum responsivity of 2.01×10^{-1} A/W and 7.32×10^9 Jones of detectivity than the other films. The current increase from nA to mA upon annealing significantly increased the photo response of the 250 °C annealed films. The hydrophilic properties improved with annealing, as confirmed by contact angle measurement. It is also further verified by the increased porosity observed from the FESEM images of the surface morphology. The transition from amorphous to polycrystalline was confirmed through XRD. The interdiffusion by annealing resulted in the formation of ternary phases like AgInS_2 and AgInSe_2 , as seen from the XRD and HRTEM data. The crystallite size that increased upon annealing reduced the dislocation density from 3.29×10^{15} to 2.73×10^{15} m^{-2} . The optical bandgap, density, extinction coefficient, and skin depth showed changes as probed by UV-visible spectroscopy. Upon annealing, the band gap was enhanced by 0.157 eV from its as-prepared state. The observed changes in optical parameters and photoconductivity make the film a suitable candidate for visible light photodetection.

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1 Introduction

Bilayer and multilayer film structures are widely used for scheming many optoelectronic devices, including photodetectors, computer disks, optical reflectors, and solar cells.^{1–4} The charge collection properties are enhanced through a SnSe/SnS hybrid bilayer absorber. The thin SnSe layer improves the fill factor and open-circuit voltage. The efficiency of the bilayer absorber is 3.65%, whereas for single SnS and SnSe layers, the efficiency is 2.87% and 1.4%.⁵ The mirrors developed from the multilayer $\text{As}_{40}\text{Se}_{60}/\text{Ge}_{25}\text{Sb}_{5}\text{S}_{70}$ films are good enough for a microcavity structure for the 1.5 μm telecommunication

wavelength.⁶ The $\text{Bi}_2\text{S}_3/\text{SnS}$ heterostructure photodetector is very useful for making high-performance optoelectronic devices.⁷ Such bilayer and multilayer structures have profound technological significance due to the intermixing among the layers. The properties of such materials are enhanced for diffusion between layers by applying various post-energy treatments. The various energy treatments like ion irradiation, laser irradiation, gamma ray irradiation, X-ray irradiation, electron beam irradiation, proton irradiation, thermal annealing, *etc.* are suitable for such layer's intermixing.^{8–14}

In this aspect, bilayer films of chalcogenides are beneficial in creating innovative nanocomposites with better transport and optical ability. The solid solution formed from the laser-induced interdiffusion of Te into As_2Se_3 of the $\text{Te}/\text{As}_2\text{Se}_3$ bilayer film resulted in an increase in optical absorption with a in bandgap.¹⁵ The thermally induced diffusing of Ag layer into $\text{Ge}_{20}\text{Se}_{50}\text{S}_{30}$ film in the bilayer $\text{Ag}/\text{Ge}_{20}\text{Se}_{50}\text{S}_{30}$ structure resulted in the modification of optical behaviour. The optical energy gap is increased by 0.15 eV due to Ag diffusion, decreasing the disorder.¹⁶ The $\text{Ag}/\text{As}_{30}\text{S}_{70}$ heterostructure in the form of multilayer and bilayer is helpful in phase gratings upon Ar^+ ion

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† Electronic supplementary information (ESI) available: FESEM images at 100 nm scale for all films, extinction coefficient, $\ln \alpha$ vs. $h\nu$ plot, individual bandgap plot and IV data for dark and light current of all the films, I - T Stability plot. See DOI: <https://doi.org/10.1039/d5ra00917k>



laser irradiation. The diffraction efficiency of gratings from bilayer film is more than that of multilayers.¹⁷ Upon laser exposure, the nanolayered Se/As₂S₃ reveals the bond switching from As–S to As–Se by Se diffusion, which results in photo-darkening phenomena.¹⁸ The new AgInSe₂ and Ag₂Se impurity phases formed from selenized Ag/In/Ag/In multilayers upon heat treatment. The formed compound exhibits n-type conduction, reducing its resistivity with annealing temperature.¹⁹ The structural, electrical, and optical entities of the In/Te structure was modified because of the interfacial indium diffusion into the Te layer upon annealing. It resulted in an enhanced hydrophobicity and photocurrent enhancement from nA to ~mA. These changes are useful for such films in photo-detectors, solar cells, and photonic devices.²⁰ In this prospect, our study is based on the bilayer film (Ag₂S/In₂Se₃) with two important chalcogenide compounds such as In₂Se₃ and Ag₂S, for their important application point of view.

In₂Se₃ belongs to A₂^{III}B₃^{VI} of the periodic table with semi-conducting behavior. The chalcogenide compound crystallizes as double-layer Se–In–Se–In–Se stacking along *c*-axis through Se.²¹ Such compound is widely used in important applications like phase-change memories, solar cells, and photodiodes. This III–VI binary compound semiconductor has a direct bandgap, which means it can directly emit photons. So, they are well suited for optoelectronics applications, which are important for photovoltaic devices that directly harvest energy from sunlight.²² The α -phase is the most common and has extraordinary piezoelectric and ferroelectric properties. It is a good photodetector as it responds spectrum of light varying from ultraviolet to near-infrared. The 2D In₂Se₃ is used the applications for intelligent sensing, phase change memory, and in-memory computing devices. It is possible due to the simultaneous coupling of photoelectric, semiconducting, ferroelectric, and phase transition properties.²³

In the other hand, silver sulfide (Ag₂S) is from I–VI group and behaves as a semiconductor with monoclinic crystal structure. It is a direct tuneable bandgap ($E_g = 0.9\text{--}1.1$ eV) PV material because of the brilliant electrical and optical properties. It possesses low toxicity, good thermal stability, high theoretical efficiency (~30%), low fabrication cost, and abundant elemental availability.²⁴ Because of its excellent functional properties, Ag₂S in its thin film form is used in solar selective coatings, photovoltaic cells, laser recording media, and photoconductor.²⁵ The optical, electronic structure, and electrical properties of nanostructured Ag₂S is determined through its microstructure. It includes the composition, size, and shape of the particles.²⁶ Ag₂S acts as a good photodetector because of its unique infrared (IR) absorption and emission capabilities.²⁷

In previous studies, the thermal annealing-induced diffusion of dopants into the bottom In₂Se₃ layer has been reported, and their potential applications have been reported. The transformation from the amorphous to crystalline phase in Ag/In₂Se₃ by heat energy resulted in the AgIn₅Se₈ phase formation with increased absorption capability, making it useful for solar cell applications.²⁸ The amorphous to crystalline transition in Bi/In₂Se₃ upon annealing changes the optical behavior, which is useful for optoelectronics and photovoltaics.²⁹ The

temperature-dependent hydrophilicity improvement is noticed by Te diffusion in Te/In₂Se₃ bilayer heterostructure film for optoelectronic applications.³⁰ Owing to the importance of different dopant diffusion into In₂Se₃, the current study reports the annealing induced Ag₂S layer mixing with the In₂Se₃ layer in Ag₂S/In₂Se₃ heterostructure at different temperatures and their significant changes in the optical, structural, electrical, surface morphology and surface wettability changes.

In this work, the effect of annealing temperature (100, 150, 200, and 250 °C) on Ag₂S/In₂Se₃ thin films was probed by X-ray diffraction (XRD) and UV-visible spectrophotometry for its structural and optical study. Surface wettability and surface morphology were studied using contact angle and field emission scanning electron microscopy (FESEM). The bilayer heterostructure was verified from the cross-sectional FESEM image. The photodetection study was carried out by the 2450 Keithley source meter at different bias voltages.

2. Experimental methods

2.1. Sample preparation

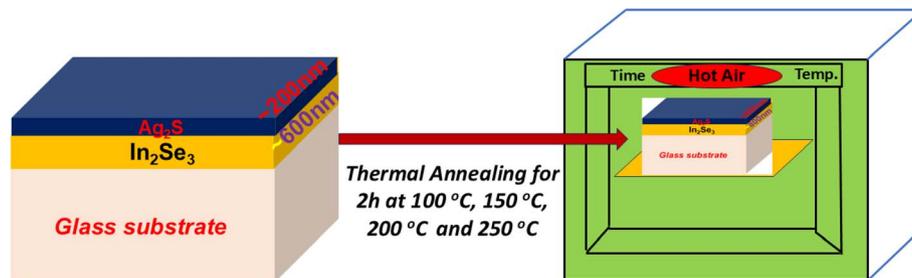
The heterostructure Ag₂S/In₂Se₃ film with 200 nm as the top Ag₂S layer and 600 nm of In₂Se₃ layer was deposited from Ag₂S and In₂Se₃ ingots (99.999% pure) purchased from Sigma Aldrich. First, the bottom In₂Se₃ layer was deposited over the cleaned glass substrate inside the Smart Coat 3 HHV coating unit. The chamber pressure was 10^{−6} Torr, and the deposition rate was 5 Å s^{−1}. The slow rotation of the sample substrate holder through a motor makes the film uniform and homogeneous. The chamber was kept at room temperature by water circulation through a chiller. Next, the top Ag₂S layer was coated on In₂Se₃ layer by maintaining the same experimental conditions. The film thickness during deposition was controlled through the thickness monitor. After that, the films were thermally annealed at four different temperatures for 2 h inside the hot air oven (Scheme 1).

2.2. Experimental characterizations

For structure identification, the prepared samples were characterized through XRD by a D8 Advance X-ray diffractometer. The data were scanned from 10–80° at a scan rate of 0.05° s^{−1} at a glancing angle of 1°. The X-ray source is CuK α , of 0.1541 nm wavelength. The instrument was operated at a voltage of 40 V with a current of 30 A. The film thickness was verified through a cross-sectional FESEM (JEOL-SEM-7601F) unit. The operating voltage is between 1 and 15 kV with a high vacuum. The images of the film surfaces were captured at different magnifications at various positions. The elemental mapping, along with the composition of the films, was taken by an energy-dispersive X-ray analysis (EDX) unit. The associated planes in the 250 °C annealed film were imaged through selected area electron diffraction (SAED) pattern. The film morphology was again verified from high-resolution transmission electron microscopy (HRTEM, JEM-2100-HRTEM) pictures.

The XPS core level and survey spectra of 250 °C annealed film was recorded from Axis Ultra Kratos Analytical, UK instrument.





Scheme 1 Bilayer film structure and thermal annealing setup.

For this, Al K_{α} X-rays (1486.6 eV) source was used at a 2×10^{-9} Torr vacuum. The surface wettability study on all the samples was carried out using a contact angle meter (DMe-211 Plus). The deionized water droplet of 0.5 μL size was used for the data acquisition with 30–35% relative humidity. The data were taken at 3–4 positions to minimize the statistical error. The optical data in the form of transmittance were recorded over 500–2500 nm wavelength range. This was done through a JASCO V-770 UV-visible spectrophotometer with 0.5 nm resolution. Suitable formulas were applied to the primary transmittance data to derive the linear and non-linear parameters.

2.3. Photodetection study

In order to perform a photodetection study, the edges of the bilayer films are scratched from both sides in such a manner that there remains an area of 0.25 cm^2 film on a glass substrate. Then, for conductive contact, silver paste was applied on the two opposite sides of the film. These electrodes, known for their simplicity and reliable performance, were used for the measurements. After that, the sample is connected to the Keithley 2450 Source with two probes. As shown in Scheme 2, the prepared film with electrode is mounted on the sample holder. For measurement under light illumination conditions, a 9W white LED bulb was used, as shown in Scheme 2. It covered the entire visible spectrum for illumination. It illuminated the 5 mm \times 5 mm sample area for the photo response study. The data was collected many times for reproducibility. Photocurrent data were recorded over -10 V to $+10$ V voltage with a 0.04 V increment. To ensure electrode uniformity, I - V and I - T data were collected at four separate positions over the film, revealing consistent results. The same procedure was repeated for all samples. The

experiment is conducted inside a closed box in a dark room at room temperature to maintain an isothermal environment. To prevent sample heating during illumination, the sample was positioned 10 cm away from the light source. First, the dark current was measured, followed by the current under illumination once the LED light was turned on. These precautions were taken to minimize temperature fluctuations and ensure accurate measurements during the experiment.

3. Results and discussions

3.1. Structural investigation: XRD analysis

Fig. 1 shows the XRD data of the as-prepared and annealed $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin films. The as-prepared sample exhibits an

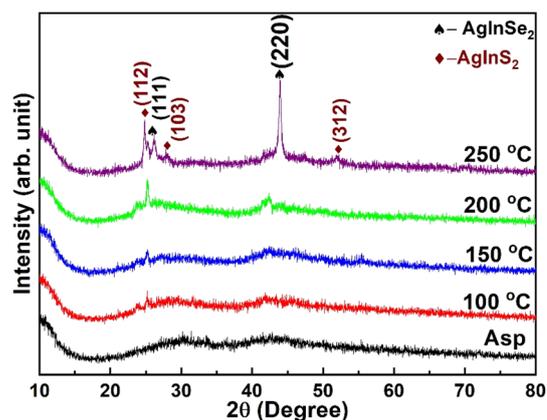
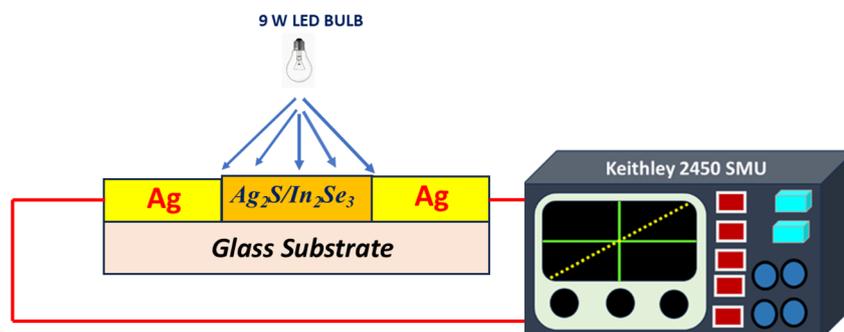


Fig. 1 Structural data by XRD for $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ films.



Scheme 2 Setup for measuring photo response.



amorphous nature, whereas the heat treatment leads to a polycrystalline behavior. The crystallinity increased with annealing temperature. This increase in the annealing temperature leads to diffusion of phase between the phases of Ag_2S and In_2Se_3 . The XRD pattern of the thin films exhibits several peaks, which denote different phases of the films. The peaks appeared around 43.82° and 26.43° corresponding to the AgInSe_2 cubic phase (ICDD: 00-023-0636) with (220) and (111) planes. Similarly, the peaks at 25.23° (112), 28.48° (103), and 52.24° (312) were also assigned to the AgInS_2 tetragonal phase (ICDD: 01-075-0117). Several structural parameters govern various parameters, such as morphology, particle size, and other optical properties. Hence, these structural parameters can be calculated from Scherrer's relation. The crystallite size (D) denotes to the coherent volume in the thin films for the respective diffraction peak. It also corresponds to the grain size of polycrystalline thin film. It can be written as,³¹

$$\text{Crystallite size}(D) = \frac{0.9\lambda}{\beta \cos \theta} \quad (1)$$

Here θ denotes Bragg's angle and β represents the full width at half maximum (FWHM). Cu $K\alpha$ line wavelength is denoted by λ (1.54 Å).

The distortion created in film dimensions compared to its initial size is represented by lattice strain (ϵ). The two varieties of such strain are: uniform strains and non-uniform strains. An isotropic contraction/expansion of the unit cell results from regular or consistent strain.³² Peak broadening is unaffected; however, the measured peaks are shifted and the lattice parameters are somewhat altered as a result. Peak broadening is brought on by uneven or nonuniform strain, which also causes atoms to shift irregularly from their initial locations.³³ Furthermore, the material's poor crystallization and numerous flaws also contribute to the uneven strain. The relation is used to compute the lattice strain,³¹

$$\text{Lattice strain}(\epsilon) = \frac{\beta \cot \theta}{4} \quad (2)$$

The density of dislocation, also known as dislocation density (δ), is defined as the length of dislocation lines per unit volume. From a thermodynamic perspective, dislocations are not as important as observable densities despite being non-equilibrium defects. This is estimated using the relationship,³¹

$$\text{Dislocation density}(\delta) = \frac{1}{D^2} \quad (3)$$

The number of crystallites is always determined by structural factors such as the size of the crystallites and the degree of agglomeration or clustering. The number of crystallite (N_C) is affected by the D value significantly and evaluated as

$$N_C = \frac{d}{D^3} \quad (4)$$

The calculated different structural data are given in Table 1. The D value gradually enhanced with annealing temperature. The high-temperature energy from the recrystallization and re-nucleation process causes the increase in crystallinity. The densification process causes the development of small nuclei that grow on their own and then merge with the more regular ones.³⁴ Many crystallites are created during the annealing process, that increases the absorption surface area. It reduced the optical bandgap by causing more light to be absorbed than transmitted.³⁵

3.2. Morphology study

The cross-sectional image of bilayer $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$, and 250 °C annealed films is shown in Fig. 2. It perfectly presents the bilayer heterostructure with two distinct layers of Ag_2S and In_2Se_3 . The top Ag_2S layer shows ~ 200 nm thickness, while bottom In_2Se_3 film is of ~ 600 nm, as seen in Fig. 2. However, the 250 °C annealed film is found with an enhanced thickness of ~ 850 nm after the intermixing of Ag_2S layer into the In_2Se_3 layer upon heat treatment. The uniformity of Ag_2S top layer was not perfect for the smaller thickness value coated within short time. The single layer formed by the intermixing upon annealing for 250 °C is shown in Fig. 2(b).

The morphological study acts an important role in deciding the applicability of the material. Fig. 3 represents the FESEM

Table 1 Calculated structural data of $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ films

Structural parameters	150 °C	200 °C	250 °C
Average crystallite size (nm)	17.42	18.11	19.12
Dislocation density, $\delta \times 10^{15}$ (m^{-2})	3.29	3.04	2.73
Lattice strain (ϵ)	0.0064	0.0066	0.0069
N_C (nm^{-2})	0.15	0.13	0.11

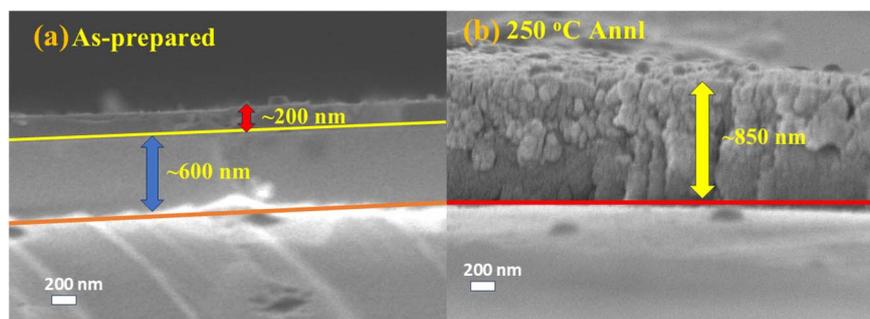


Fig. 2 View of cross-sectional FESEM for bilayer (a) $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$, and (b) 250 °C $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ annealed film.



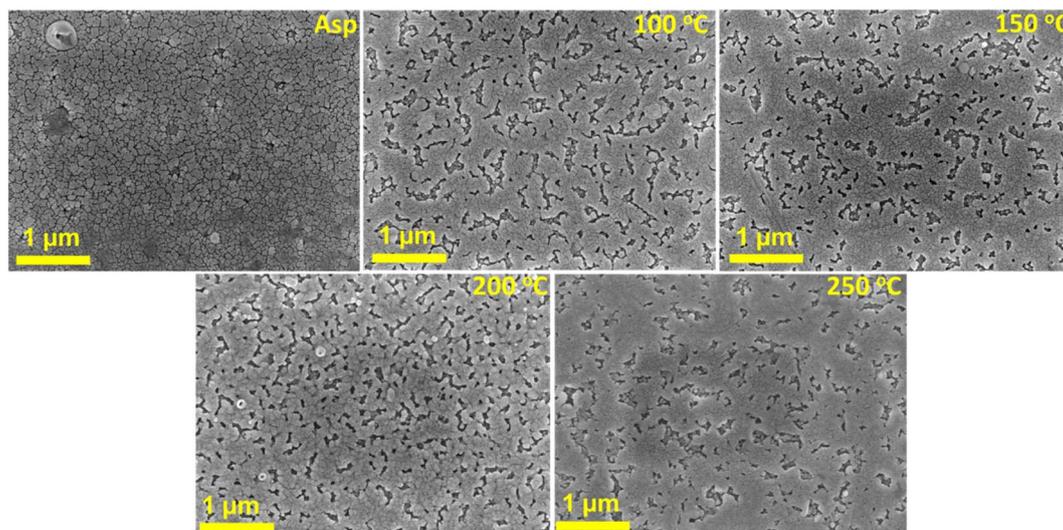


Fig. 3 FESEM image of different $\text{Ag}_2\text{Se}/\text{In}_2\text{Se}_3$ films at 1 μm scale.

images of the thin films. With the enhancement in the annealing temperature, the particle size increases. Such an increase in the grain boundary also enhanced the porosity of the material. This also affects the absorbance as well as the surface wettability property of the sample. The 100 nm scale FESEM images for all the films are shown in Fig. S1.†

The elemental mapping is shown in Fig. 4. The elemental mapping shows Ag, Se, S, and In presence in the films as verified from the EDX spectra Fig. 4(f). The peak at 2.98 keV belongs to the Ag-atom, while 1.379 keV peak referred as Se- K_{α} atom. The peaks located at 2.30 and 3.28 keV referred as S and In elements. The extra peaks observed at 0.276 keV and 0.542 keV are attributed to carbon. Carbon tape was used for conducting purposes during data recording. Likewise, the low-intensity 2.133 keV peak corresponds to Au. It was taken as a coating material on the sample surface to minimize charging effects.

3.3. TEM analysis

The TEM images of the sample at two different scales are shown in Fig. 5(a and b). Fig. 5(c) shows the HRTEM pictures of the sample showing the existence of both AgInSe_2 and AgInS_2 phases. The atomic spacing is 3.35 Å (111) and 2.05 Å (220) for Ag_2InSe_2 . Similarly, the atomic spacing of 3.31 Å (111) corresponds to the AgInS_2 phase. Furthermore, the SAED pattern also supports the XRD pattern of the material and confirms the presence of different phases (Fig. 5(d)).

3.4. XPS analysis

XPS analysis plays a crucial part in evaluating the characteristics of $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin films, particularly in identifying their elemental composition. Fig. 6(a) exhibits the survey spectra of 250 °C annealed thin films. Here, there are several peaks appeared in the spectra for In 3d, C 1s, Ag 3d, S 2p, and Se 3d. The exact state of the elemental composition can be visualized in the core-level peak of the thin films. Fig. 6(b) represents the

Ag 3d core level spectra, which typically feature two significant peaks corresponding to the spin-orbit splitting at binding energies around 368 eV for Ag 3d_{5/2} and 374 eV for Ag 3d_{3/2}.³⁶ This shows the metallic character of Ag (0). The S 2p peak exhibits (Fig. 6(c)) a doublet structure with 161 eV (S 2p_{3/2}) and 166 eV (S 2p_{1/2}) peaks.³⁷ The In 3d spectrum shown in Fig. 6(d) exhibits peaks at around 444.5 eV and 451.5 eV, corresponding to the 3d_{5/2} and 3d_{3/2} components, respectively.³⁸ The Se 3d peak (Fig. 6(e)) appears near 54.5 eV, marking the spin-orbit coupling characteristics specific to this thin film.³⁹

3.5. Optical analysis

The annealing-induced optical changes are clearly noticed in the transmittance data obtained from the UV-visible spectrometer in Fig. 7(a). The transmission power gradually increased with annealing along with the shift of absorption edge to lower wavelength. This indicates the increase in the energy gap upon annealing. The appearance of fringe patterns in the films infers film homogeneity. The increase of transmittance varies from 40–80% across the wavelength region 800–2000 nm, mostly in near IR regions. The enhanced transmittance with annealing might be for the defect state change in the gap regime and the defect/disorder concentration.⁴⁰ Since the observed transmittance is less in visible regions (500–800 nm), the absorbance is more, making it suitable for photo-detection in visible light regions. It indicates that the films are completely absorbent in the visible regime, making them suitable for optical windows in photovoltaic cells. The higher transparency in the NIR range comes from the free electron interaction with incident energy that led to a change in the polarization of light, making it a more efficient material for IR lenses and waveguides used for temperature monitoring and detection.^{20,41}

The absorbance strength was evaluated from the transmittance spectrum by using the formula $\alpha = \left(\frac{1}{t}\right) \ln\left(\frac{1}{T}\right)$ with 't'



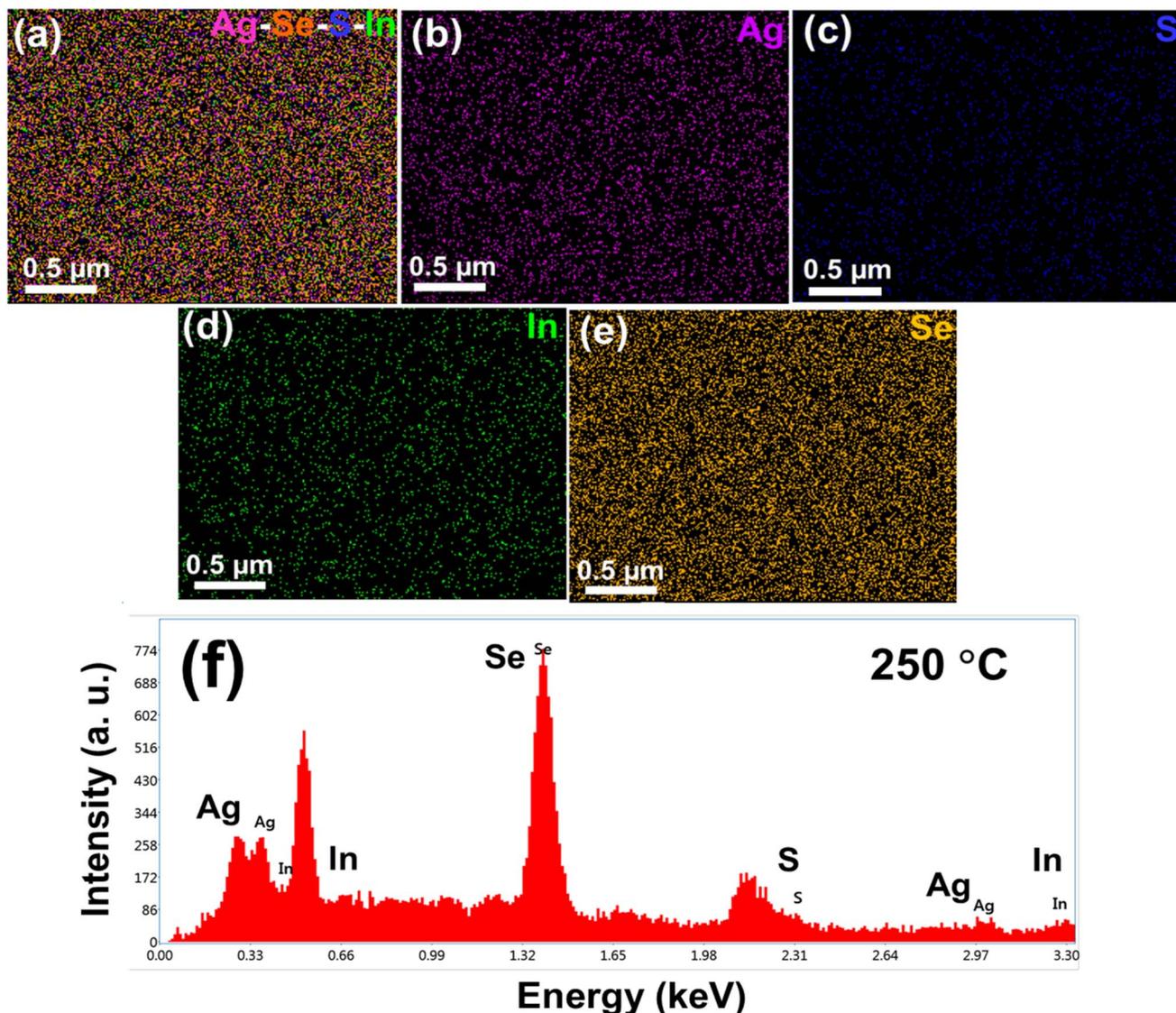


Fig. 4 (a–e) Elemental mapping and (f) EDX spectra of 250 °C annealed $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin film.

as the film thickness and ' T ' as the transmittance value. The calculated absorption coefficient ' α ' values are used to evaluate the other important optical parameters like skin depth, extinction coefficient, bandgap, optical density, *etc.* The important metric associated with ' α ' is the skin depth, the so-called penetration depth (δ). The definition of it lies in the value that equals $1/e$ times the photon density at the surface level. This parameter is well-linked with the conductivity in semiconducting films and determined by the reciprocal of ' α ' ($\delta = 1/\alpha$).²⁰ It is observed that the skin depth gradually decreases with an increase in photon energy and saturates at higher energy regions (Fig. 7(b)). The value of δ is smaller for the as-prepared film than the annealed one since high absorbance brings down the transmittance, and light passes through the film with less amount.⁴² The reverse is for the annealed film with more transmittance and high skin depth. The loss of light while passing through the film by scattering and absorption is

represented by the extinction coefficient (k). It is obtained from the wavelength and corresponding absorption coefficient by $k = \frac{\alpha\lambda}{4\pi}$.²⁰ The variation of k at different annealing conditions is presented in Fig. S2.† It infers a lower value for annealed sample over as-prepared bilayer film. Lower ' k ' values signify the comparatively smoother surface and low loss of light energy by scattering and absorption. Optical density (OD) also measures the absorption strength of the films. It is linked to the film thickness and ' α ' by $\text{OD} = \alpha \times t$. The change in photon energy upon annealing is presented in Fig. 7(c). Its value increases with ' $h\nu$ ' and has less magnitude for the annealed sample (Fig. 7(c)).

The vital parameter of the semiconducting films is the energy gap or optical bandgap (E_g), which is dependent on ' $h\nu$ ' and the absorption coefficient through the relation,⁴³

$$(\alpha h\nu) = B(h\nu - E_g)^m \quad (5)$$



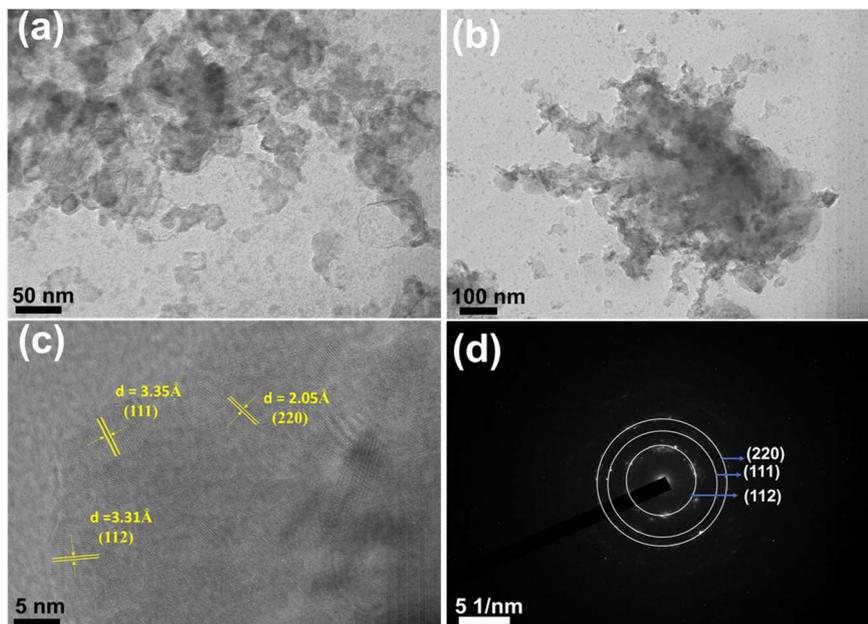


Fig. 5 (a and b) TEM picture, (c) HRTEM picture, and (d) SAED pattern of 250 °C annealed $\text{Ag}_2\text{Se}/\text{In}_2\text{Se}_3$ thin film.

The relation has the exponent 'm', which has separate values for the type of electronic transitions between gap regions. The different exponent factors for "m" as $2, \frac{1}{2}, 3,$ and $3/2$ correspond to indirect allowed, direct allowed, indirect prohibited, and direct prohibited transitions. Fig. S4† presents the direct optical

band gap as calculated through the linear fitting between $(\alpha h\nu)^2$ with $(h\nu)$. The x-intercept presents the bandgap value where the slope gives the Tauc parameter. The films' direct band gap was increased from 2.199 eV (as-prepared $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$) to 2.337 eV upon annealing at 250 °C (Fig. 7(d)). This increase in E_g is in

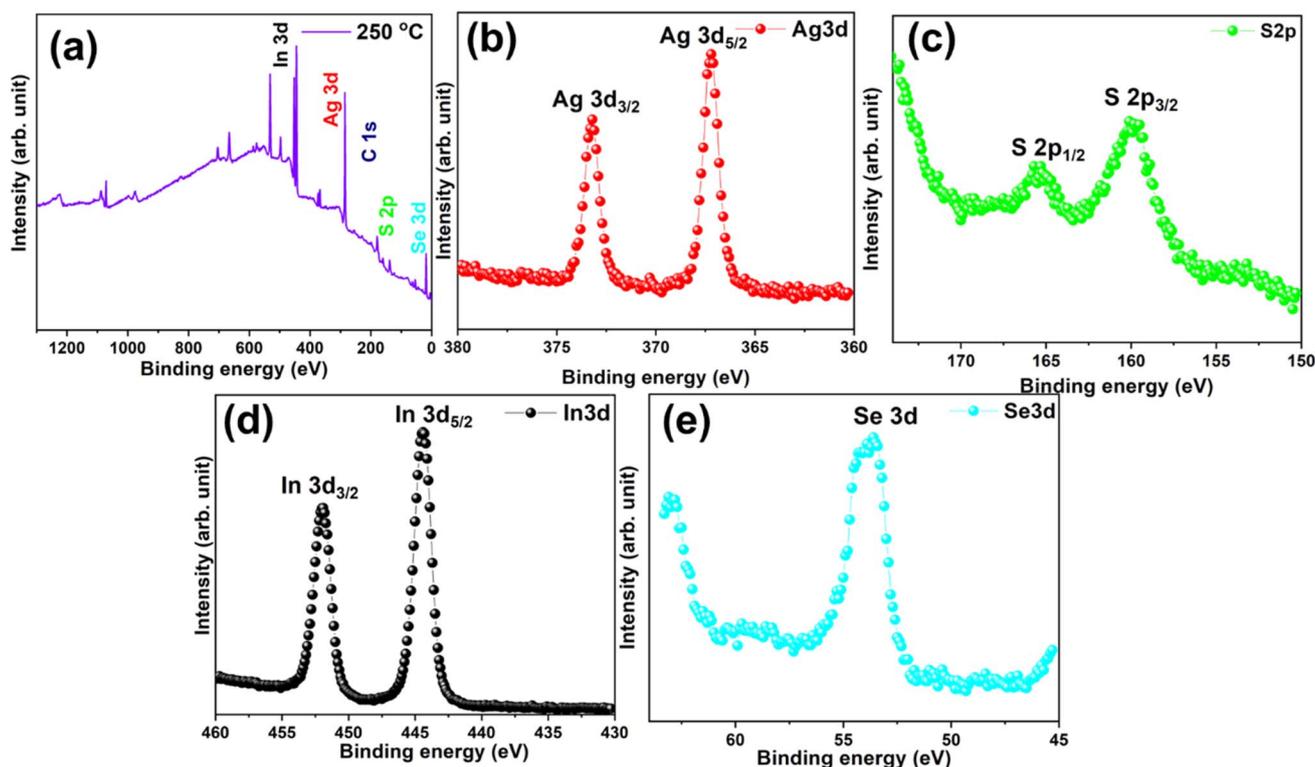


Fig. 6 XPS (a) survey, core level (b) Ag 3d, (c) S 2p, (d) In 3d and (e) Se 3d spectra of 250 °C annealed $\text{Ag}_2\text{Se}/\text{In}_2\text{Se}_3$ thin film.



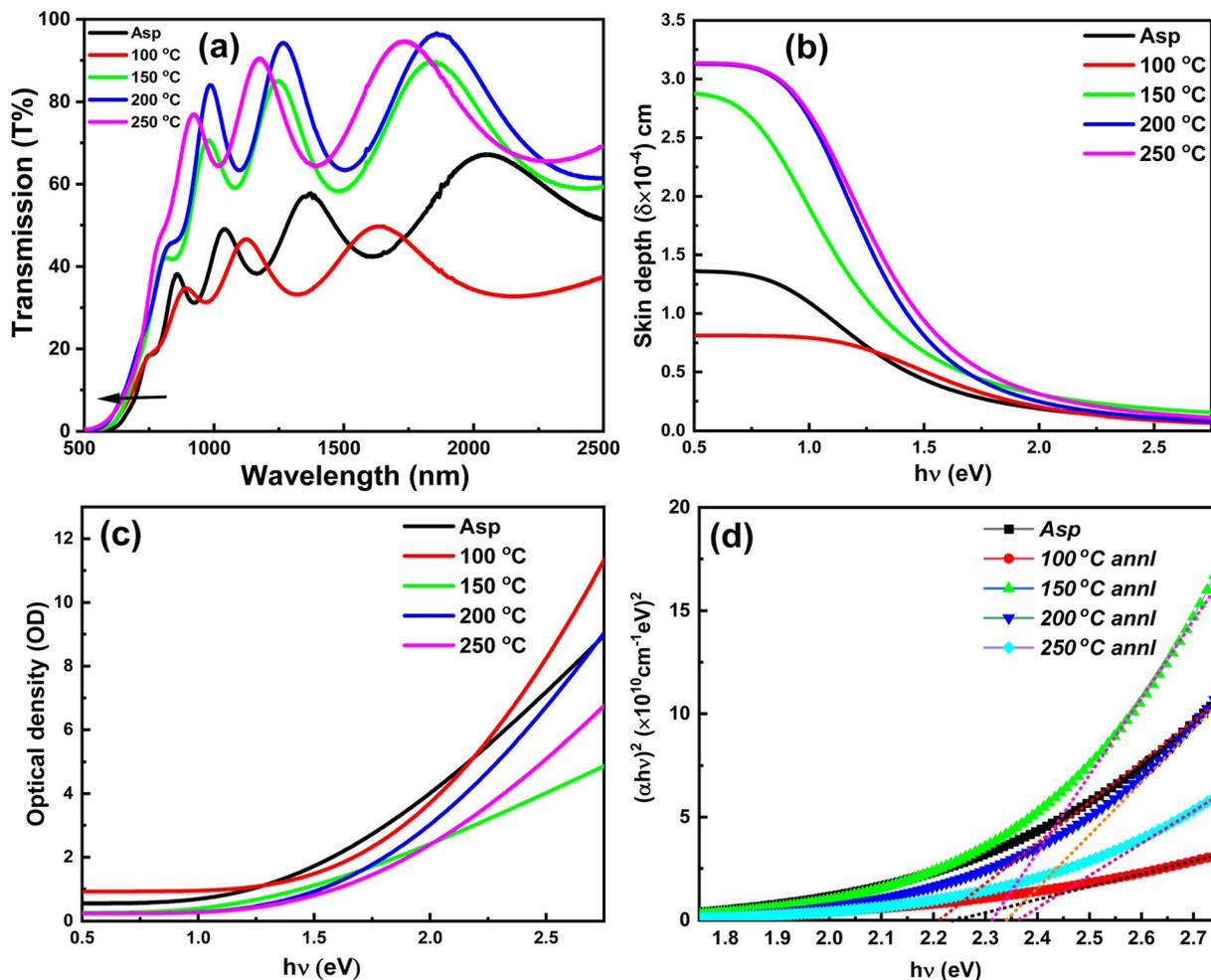


Fig. 7 (a) Transmittance change (b) skin depth (c) optical density (d) bandgap of the films.

accordance with the model developed by Davis and Mott, so-called “density of state model”.⁴⁴ The enhancement in E_g is because of the decrease in defects with increased structural ordering, as seen from the XRD data. The decreased defect states are represented by the Tauc parameter. The B^2 values are 1.81×10^{11} , 2.01×10^{11} , 2.96×10^{11} , 3.94×10^{11} , and $4.43 \times 10^{11} \text{ cm}^{-2} \text{ eV}^{-2}$ for as-prepared, 100, 150, 200, and 250 °C annealed samples respectively. The inverse relation between the Tauc parameter and disorder strength results in the increased value of B .⁴⁵ The formation of more saturated bonds with heat treatment reduces the defect states.⁴⁶ The direct relation with the defect state is presented by another important quantity called Urbach energy (E_u). It is calculated at a very low absorption regime. The E_u was calculated from the relation⁴⁷

$$\alpha = \alpha_0 \exp\left(\frac{h\nu}{E_u}\right). \text{ Here, } \alpha_0 \text{ refers to the corresponding '}\alpha\text{' value}$$

at the bandgap. By plotting $\ln \alpha$ vs. $h\nu$ (Fig. S3†) and using linear fit, the inverse of slope depicts E_u value. The E_u values are 307, 289, 267, 204, and 198 meV for as-prepared, 100, 150, 200, and 250 °C annealed samples respectively. The decreasing trend of the E_u value infers the reduction of defect states due to structural ordering.⁴⁸

3.6. Surface wettability property study

The interaction of the fluid with the sample surface is determined through surface wettability. Such wetting property is common; however, it varies based on chemical nature of both liquid and solid phases. The surface wettability nature of the films is confirmed by their hydrophilicity or hydrophobicity nature as measured through the contact angle between the two phases. The surface with water-loving is called the hydrophilic one with its contact angle (θ_c) below 90°. On the other hand, the surface with water repelling is called the hydrophobic one with θ_c greater than 90°. The observed contact angle images for different films are presented in Fig. 8. The as-prepared $\text{Ag}_2\text{Se}/\text{In}_2\text{Se}_3$ bilayer film has a θ_c value of 101°, which indicates its hydrophobic behaviour. However, the contact angle value decreased upon annealing and was found to be 83° for the 250 °C annealed film. This shows the transition of hydrophobicity to hydrophilicity upon annealing. The better photocatalytic performance of the sample depends on the hydrophilic behavior of the surface.⁵⁰ The FESEM surface images clearly show the increase in porosity that infers the appearance of a hydrophilic nature at the higher annealing temperature.



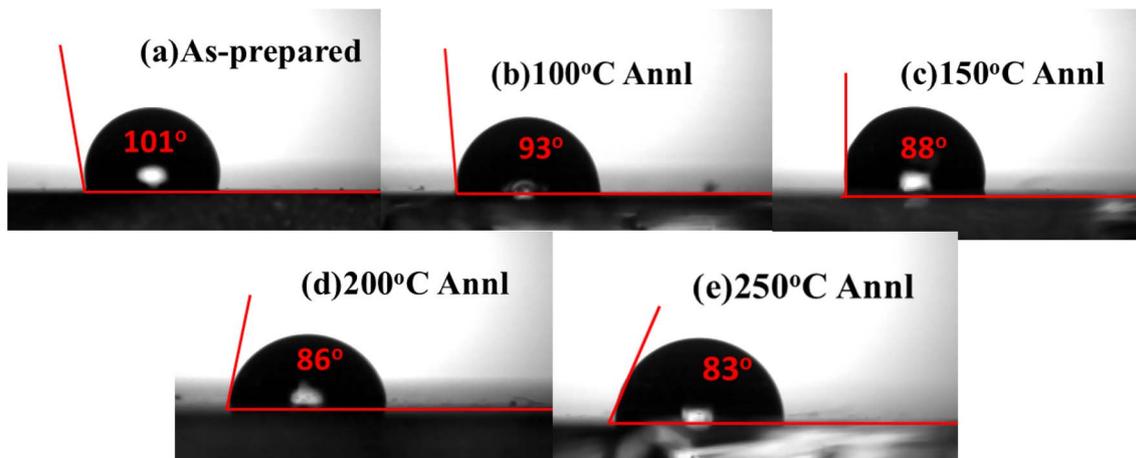


Fig. 8 (a–e) Contact angle pictures of different film samples.

The wettability nature is purely associated with sample surface morphology. Appropriate surface modification techniques can modify it. Thermal treatment allows for modifying the hydrophilicity of the surface of a material. Hydrophilic surfaces possess high surface energy that can accelerate the photocatalysis rate over hydrophobic ones.⁵¹ The surface energy was evaluated from ‘Young’ equation, $\gamma_{se} = \frac{\gamma_w (1 + \cos \theta_C)^2}{4}$, where γ_w water surface tension (71.99 Nm m^{-1}).⁵² The degree of binding strength among film surface and water droplet is expressed by work of adhesion (W_{sl}). It is calculated by the formula,⁵³ $W_{sl} = \gamma_w(1 + \cos \theta_C)$. The value of γ_{se} and W_{sl} are given in Table 2. By dispersing water droplets and forming the film over the hydrophilic surface, it allows light transmittance and reduces pollutants through the photocatalysis process.⁵⁴

3.7. Photodetection study

The logarithmic I - V plots under light and dark conditions for each film are shown in Fig. 9 (a–g). The linear I - V variation is presented in Fig. S5† indicating the ohmic nature. The plots reveal distinct, symmetric curves for each thin film under both lighting conditions, with the photocurrent consistently exceeding the dark current in each film. Such photocurrent increment is attributed to light–material interactions and charge separation.⁵⁵ The maximum photocurrent *i.e.* light (I_L) and dark (I_D) current for each film as obtained from Fig. S5† is presented in Table 3. The calculated photosensitivity of each film by using eqn (6) is shown in Table 3. It has been observed that all the films exhibit notable photosensitivity; however, 250 °C annealed $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin film sample demonstrates superior photodetection performance over other samples.

Increasing the annealing temperature of $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin films improved the photodetector performance, including higher photoresponsivity and detectivity due to improved crystallinity.⁵⁶ The performance of a photodetector under low- and high-light state is primarily explained by the generation of electron–hole pairs proportional to power density. Depositing an Ag_2S layer on In_2Se_3 enhances the carrier concentration in the In_2Se_3 layer. Additionally, performance is influenced by oxygen adsorption (in the dark) and desorption (under illumination) at the film’s surface. In the darkness, adsorbed oxygen ions (O^-) capture free electrons ($\text{O}_2 + e^- \rightarrow \text{O}_2^-$). Upon illumination, electron–hole pairs are generated, and holes facilitate oxygen desorption, releasing additional free electrons into the conduction band, thereby increasing the photocurrent.⁵⁷

Additional key parameters like, detectivity (D^*) and photoresponsivity (R) also determines the photodetector performance. These metrics are determined using specific mathematical relationships and are also tabulated in Table 3.^{58,59}

$$\text{Photo sensitivity} = \frac{I_L - I_D}{I_L} \times 100\% \quad (6)$$

$$\text{Responsivity}(R) = \frac{I_L}{A \times P_{in}} \quad (7)$$

$$\text{Detectivity}(D^*) = R \sqrt{\frac{A}{2eI_D}} \quad (8)$$

Here, the value of A (active surface area) = 0.25 cm^2 and P (incident light’s power density) = 20 m W cm^{-2} . The other constant ‘ e ’ represents electron charge.

Table 2 Estimated parameters of contact angles of the films

Parameters/film	As-prepared	100 °C annl	150 °C annl	200 °C annl	250 °C annl
θ_C (degree)	101	93	88	86	83
γ_{se} (mN m^{-1})	11.784	16.162	19.275	20.595	22.651
W_{sl} (mN m^{-1})	58.253	68.223	74.502	77.011	80.763



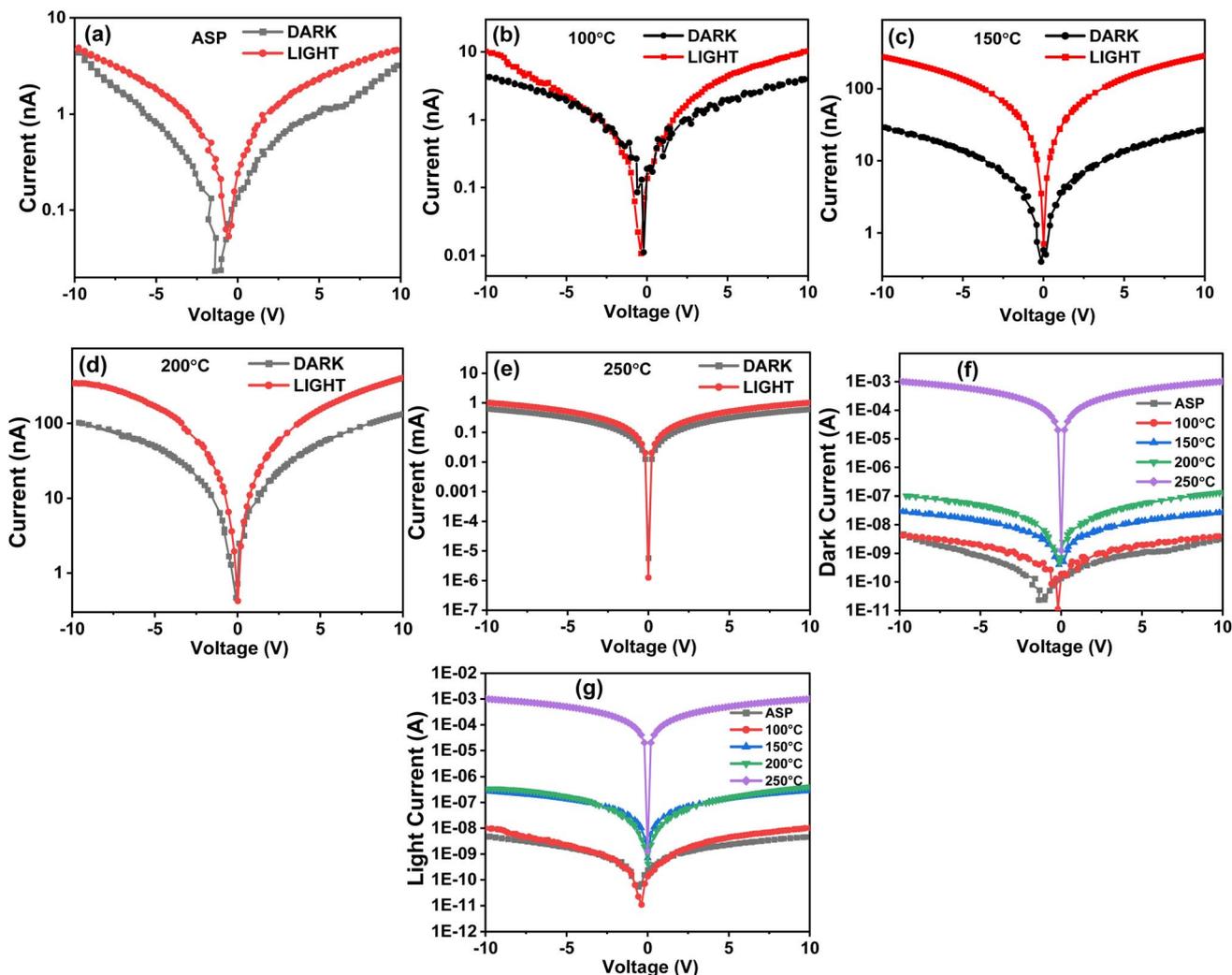


Fig. 9 I - V characteristics plots of as-prepared and annealed $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin films plotted in logarithmic scale for both dark and light conditions (a) asp, (b) 100 °C, (c) 150 °C, (d) 200 °C, (e) 250 °C, combined I - V plots of all the samples (f) in dark condition and (g) in light condition.

The temporal photo response plot *i.e.*, current *versus* time (I - T) curves for thin film samples annealed at 150, 200, and 250 °C are presented in Fig. 10(a-c), showing multiple on/off cycles measured with different biasing voltages of 2.5, 5, 7.5, and 10 V. These curves reveal an increase in current under light illumination, which decreases immediately once the light is turned off. The instantaneous rise in current with light exposure is attributed to the increased drift velocity of carriers. Variations in the maximum photocurrent values among the samples are

likely due to defect states specific to each material. The results confirm a substantial increase in current under illumination for all three thin films with an increase in biasing voltage, indicating continuous carrier generation during light exposure. The increasing electric field across the photodetector is the main cause of the rise in photocurrent with higher bias voltages. More charge carriers accelerated by this greater electric field can contribute to the current as a result of the more effective separation of photogenerated hole-electron pairs, which

Table 3 The figure of merits of all the $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin films

Sample	I_L (A)	I_D (A)	$I_L - I_D$ (A)	Photo sensitivity (%)	Responsivity (R) (AW^{-1})	Detectivity (D^*) (Jones)
Asp	4.62×10^{-9}	3.19×10^{-9}	1.42×10^{-9}	30.88	9.25×10^{-7}	1.44×10^7
100 °C	1.03×10^{-8}	3.95×10^{-9}	6.35×10^{-9}	61.62	2.06×10^{-6}	2.89×10^7
150 °C	2.86×10^{-7}	2.66×10^{-8}	2.59×10^{-7}	90.67	5.72×10^{-5}	3.09×10^8
200 °C	4.04×10^{-7}	1.33×10^{-7}	2.71×10^{-7}	66.98	8.09×10^{-5}	1.95×10^8
250 °C	1.01×10^{-3}	6.07×10^{-4}	4.01×10^{-4}	39.78	2.01×10^{-1}	7.32×10^9



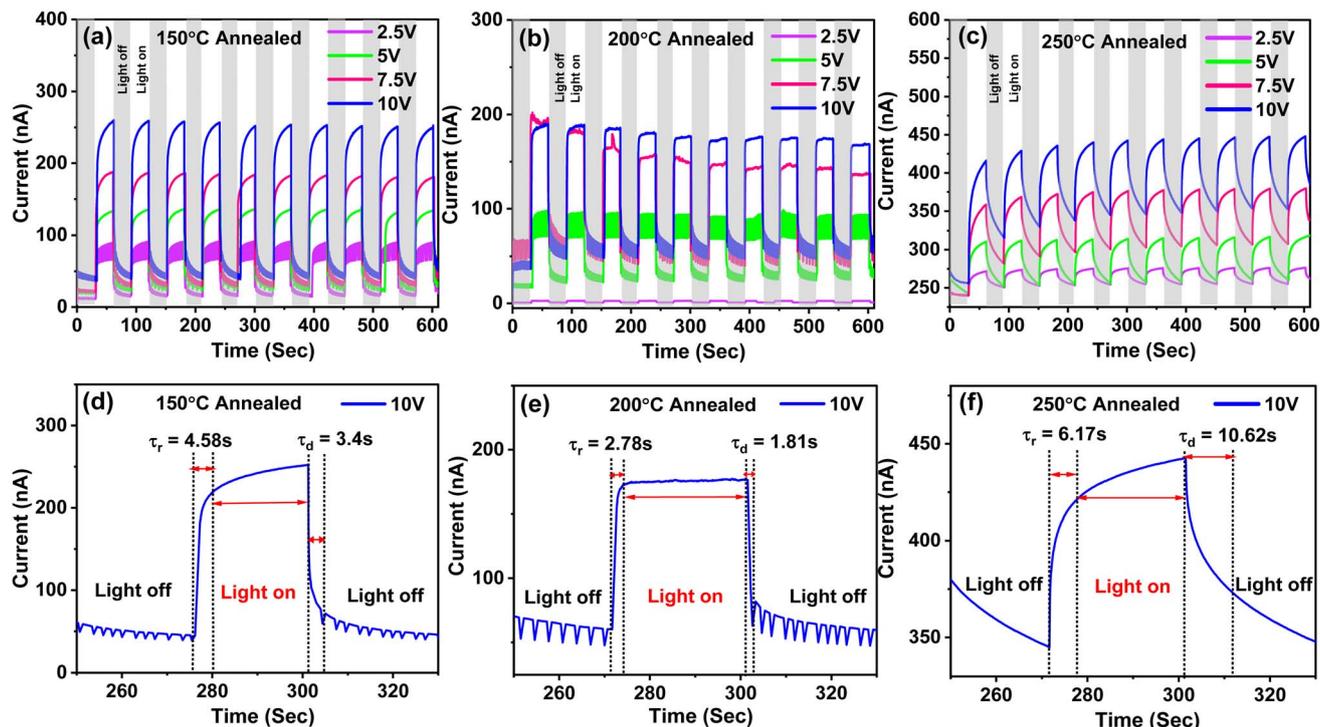


Fig. 10 Temporal photo response curve showing the variation between current and time for different biasing voltages of 2.5, 5, 7.5, and 10 V for different annealed thin films (a) 150 °C, (b) 200 °C, and (c) 250 °C, respectively. Variation in the rise and fall time of photocurrent for different annealed thin films (d) 150 °C, (e) 200 °C, and (f) 250 °C, respectively.

reduces recombination by shortening their transit time and raising the carrier drift velocity. Higher bias voltages can further increase the area for efficient charge production and collection by widening the depletion region, which will increase the photocurrent even more.

When the light is switched off, the photocurrent decreases gradually, likely due to the recombination of injected free carriers with trapped carriers. Additionally, certain temporary variation in photocurrent action is due to change in carrier transport within the devices and for non-radiative pathways. The specific peak between 250 to 330 seconds is selected for all the three films for analysis as illustrated in Fig. 10(d–f). Such peak provides important information towards the performance of each thin film. The associated current values such as (I_{on}) and (I_{off}) for each rise and decay phase of the I - T curves are derived from this peak analysis. These values, along with the I_{on}/I_{off} ratios for the three samples, are compiled in Table 4.

The decay time (τ_d) and rise time (τ_r) are key parameters in a photodetector's response curve, reflecting how quickly the device reacts to light and comes back to its baseline state after

the light is switched off. Here, τ_r represents the time it need for the photodetector's output to increase from 10 to 90% of its peak current when exposed to light. A shorter τ_r indicates a faster reaction to the onset of light, showing how swiftly the photodetector transitions from no signal to a detectable output. Conversely, the decay time (τ_d) refers to the time required for the output current to decrease from 90% to 10% of its peak value after the light source is removed.⁶⁰ The shorter ' τ_d ' indicates that the photodetector can quickly reset or recover, minimizing any residual effects from the previous light stimulus. Both rise time and decay time are crucial for assessing a photodetector's performance. The fast rise time enables the rapid detection of light changes, which is vital for applications needing swift responses to variations in light intensity. Likewise, a short ' τ_d ' ensures the detector can promptly recover, allowing it to accurately respond to subsequent changes in light without being affected by prior illumination. The τ_r and τ_d values for the photodetector are derived from Fig. 10(d–f) and summarized in Table 4. The I - T stability curve shown in Fig. S6† presents the time-dependent current response of the 250 °C

Table 4 Photodetector parameters for Ag_2S/In_2Se_3 thin films at rise and decay conditions

Sample	During rise				During decay			
	I_{on} (nA)	I_{off} (nA)	I_{on}/I_{off}	τ_r (s)	I_{on} (nA)	I_{off} (nA)	I_{on}/I_{off}	τ_d (s)
150 °C	219.26	40.01	5.48013	4.58	262.05	59.02	4.44002	3.4
200 °C	172.64	59.63	2.89519	2.78	176.33	64.79	2.72156	1.81
250 °C	421.51	344.94	1.22198	6.17	442.73	373.33	1.18589	10.62



annealed $\text{Ag}_2\text{Se}/\text{In}_2\text{Se}_3$ thin film over a duration of 3600 seconds (~ 1 hour). It demonstrates excellent electrical stability over prolonged operation, making it a promising candidate for reliable and durable photodetector applications, especially where consistent long-term performance is crucial.

The performance of the annealed $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin films in terms of photodetection is quite good as it shows better responsivity and detectivity. The short rise and fall time of the photocurrent of the thin films testifies to their capability as efficient photodetector devices. Based on the photodetection study of annealed $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ thin films with a maximum responsivity of 2.01×10^{-1} A/W and detectivity of 7.32×10^9 Jones several potential applications such as fabrication of optoelectronic devices, environmental monitoring, communication, imaging, and sensing can be predicted. This study also provides crucial information regarding the effects of enhancing the performance of thin films after increasing the annealing temperature to a certain extent. This study paves the path for the preparation of similar kinds of thin film materials with various optoelectronic applications.

4. Conclusions

The observed changes in the optical, structural, morphology, electrical, and surface wettability in $\text{Ag}_2\text{S}/\text{In}_2\text{Se}_3$ heterostructure film upon annealing at various temperatures demonstrated its applicability in photodetection. The 250 °C annealed film demonstrated good photodetection ability with a maximum responsivity of 2.01×10^{-1} A/W and 7.32×10^9 Jones of detectivity over the other films as well as good stability over a longer period. The photocurrent at both light and dark conditions is in the range of mA over the nA range for other films. The increase in surface energy of the annealed film and the transition of hydrophobicity to hydrophilicity upon annealing makes the annealed film suitable for better photocatalysis applications. The increase in optical bandgap from 2.199 eV from its as-prepared state to 2.337 eV for the 250 °C annealed film signifies the reduction in disorder and increase in crystallinity. The increased crystallite size for the annealed film, as observed from the XRD study, reduces the dislocation density. The development of both AgInSe_2 and AgInS_2 phases in the annealed film confirms the interdiffusion of the top layer into the bottom layer upon annealing. The cross-sectional FESEM image confirms such diffusion, and the surface morphology of the films changed with more porosity in the film, resulting in more hydrophilic behavior. The TEM study further confirmed the new phases and corresponding planes present in the annealed film. The XPS study verified the chemical states of the corresponding elements. The observed changes in the optical parameters and electrical changes make such films for useful photodetection and optoelectronic applications.

Data availability

All the data related to the present work are included in the manuscript and ESI.†

Conflicts of interest

There are no conflicts to declare.

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